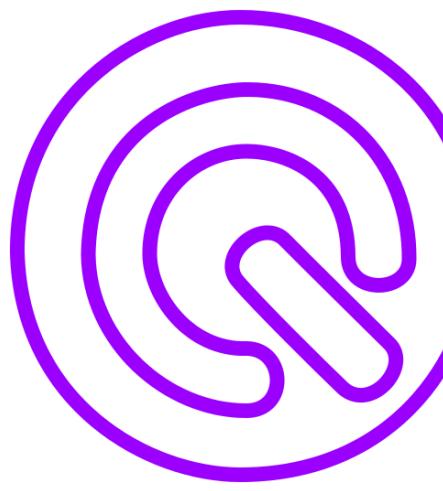


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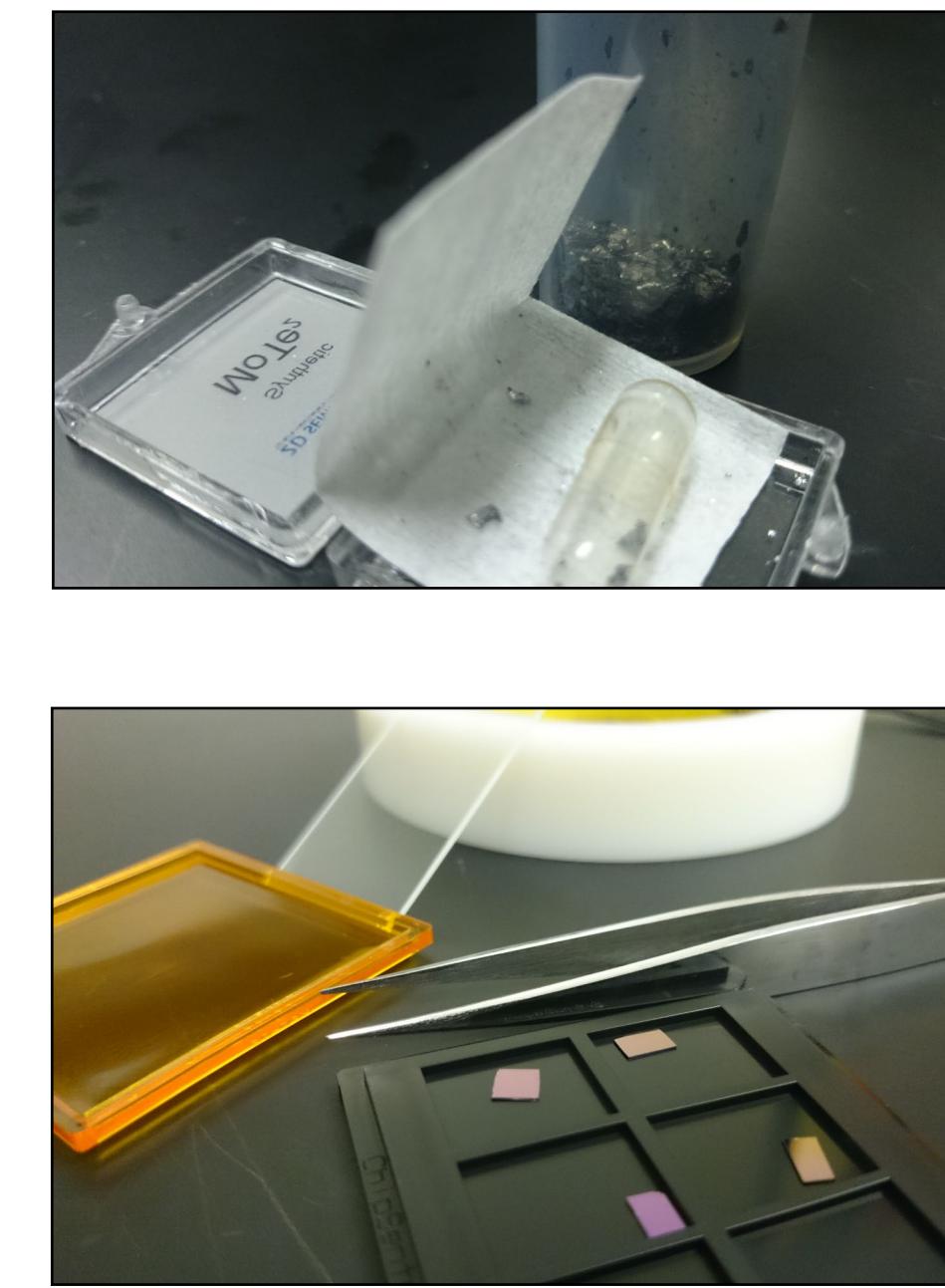
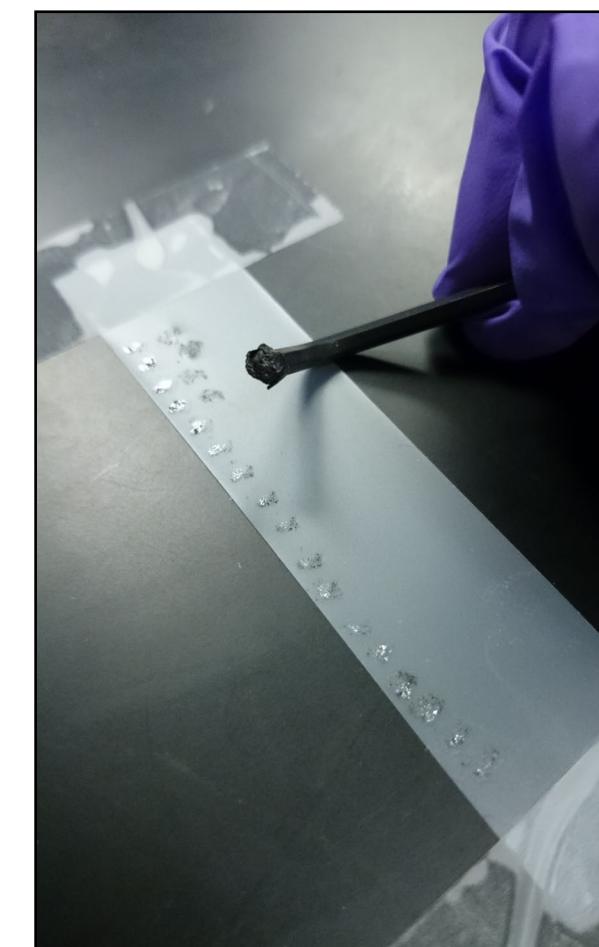
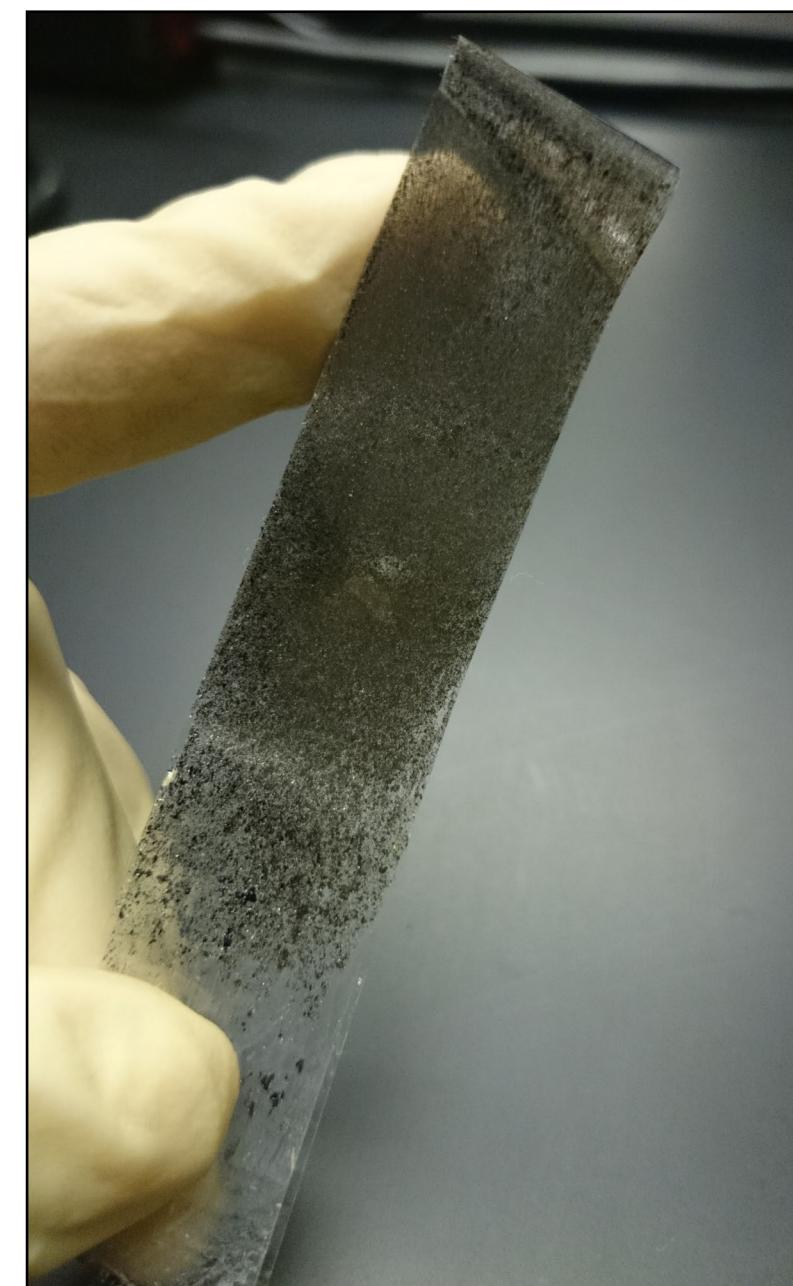
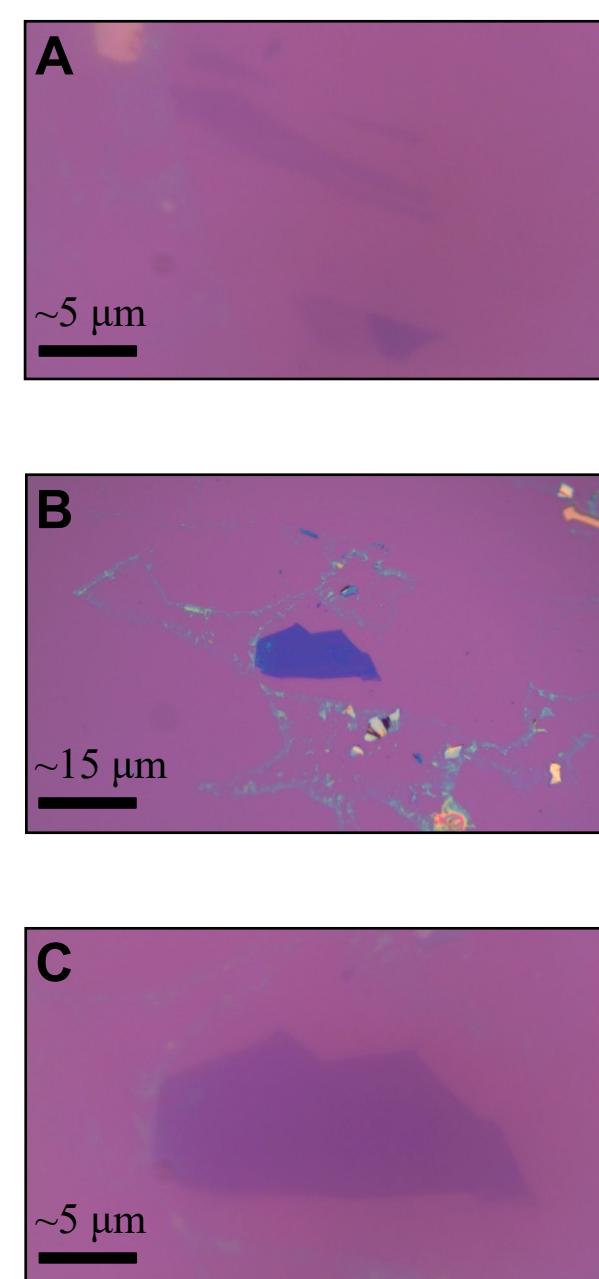
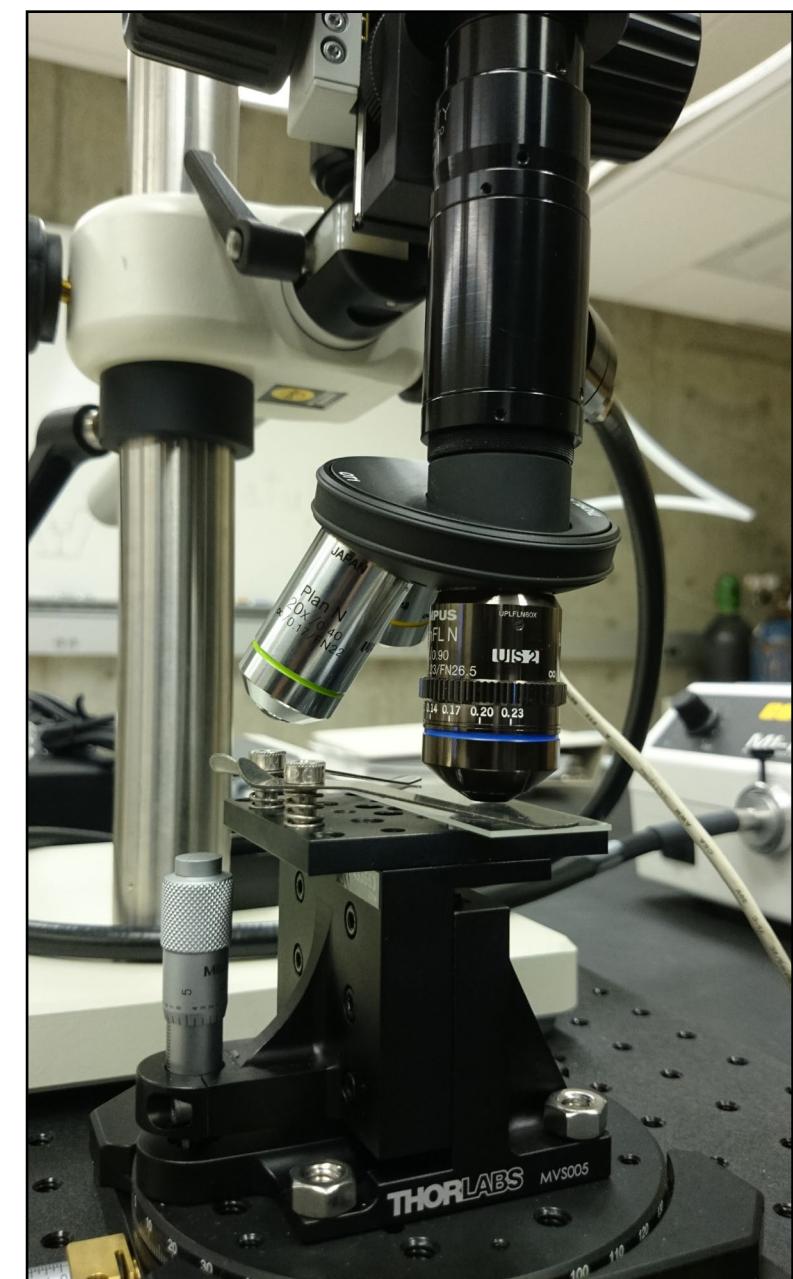
Synthesis and Fabrication of Nanoscale 2-D Semiconductor Heterostructures from Graphene, h-BN, and Few-Layered Transition Metal Dichalcogenides

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University of California, Riverside

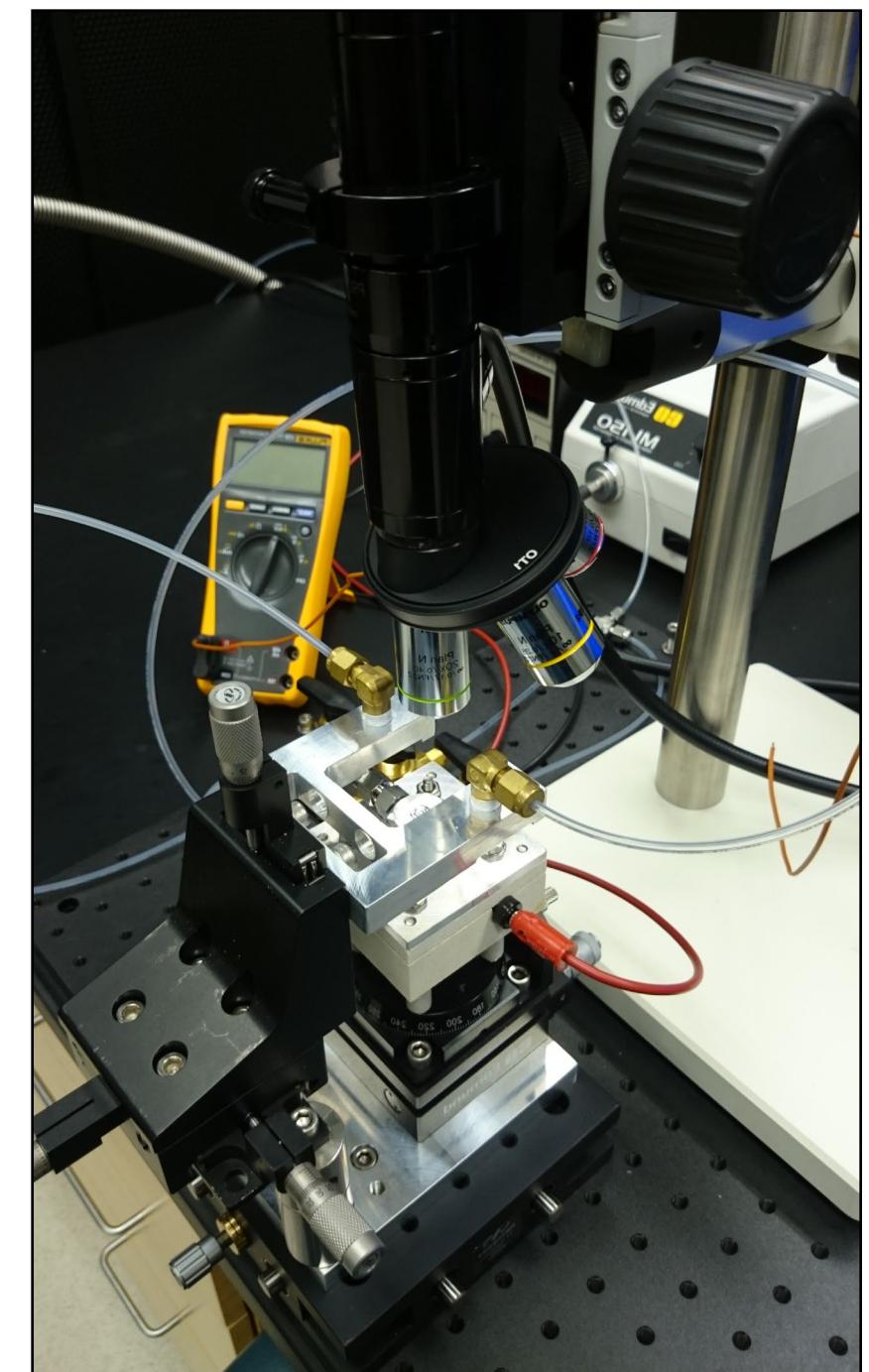
¹Department of Materials Science and Engineering,²Quantum Materials Optoelectronics Lab,³Department of Physics and AstronomySoCAL
materialsQuantum Materials
Optoelectronics Lab

Fabrication Basics

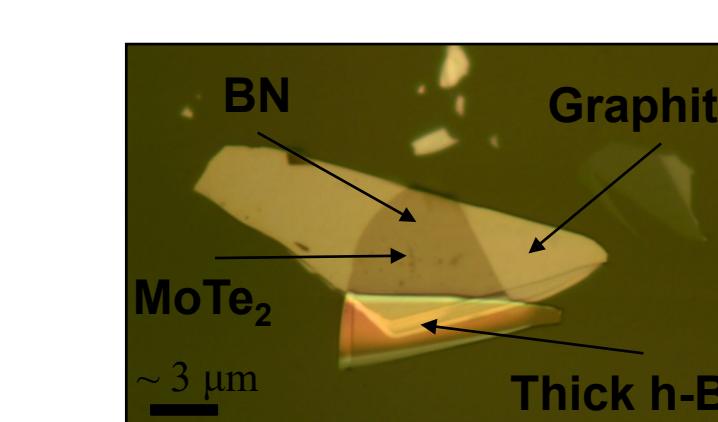
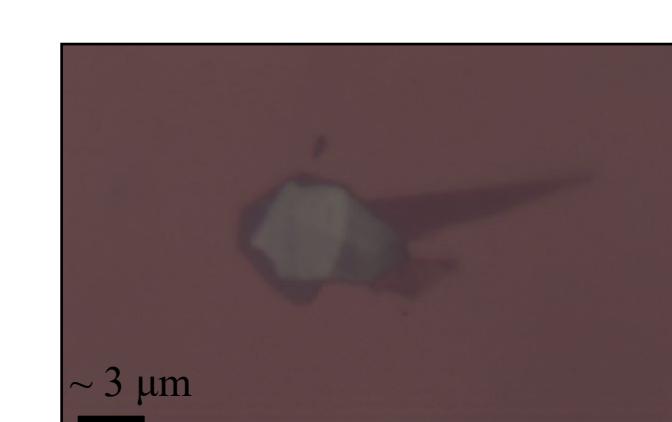
Optical Images:
[A] Graphene 60x
[B] Graphene 20x
[C] Graphene 60x

Graphene is the easiest semiconducting material to exfoliate. Various methods of mechanical exfoliation are employed to accommodate various crystal lattice structures. Graphene is cheaper and more abundant than synthetic TMD semiconductors in the bulk crystal form. Substrates are always placed into clean chip carriers to prevent cross-contamination. Pictures of ideal flake specimens are shown.

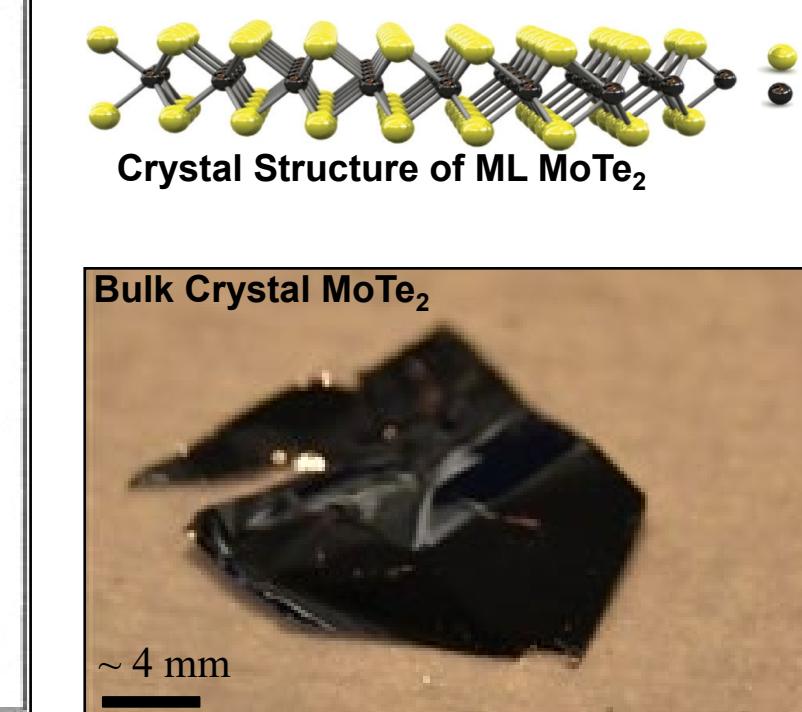
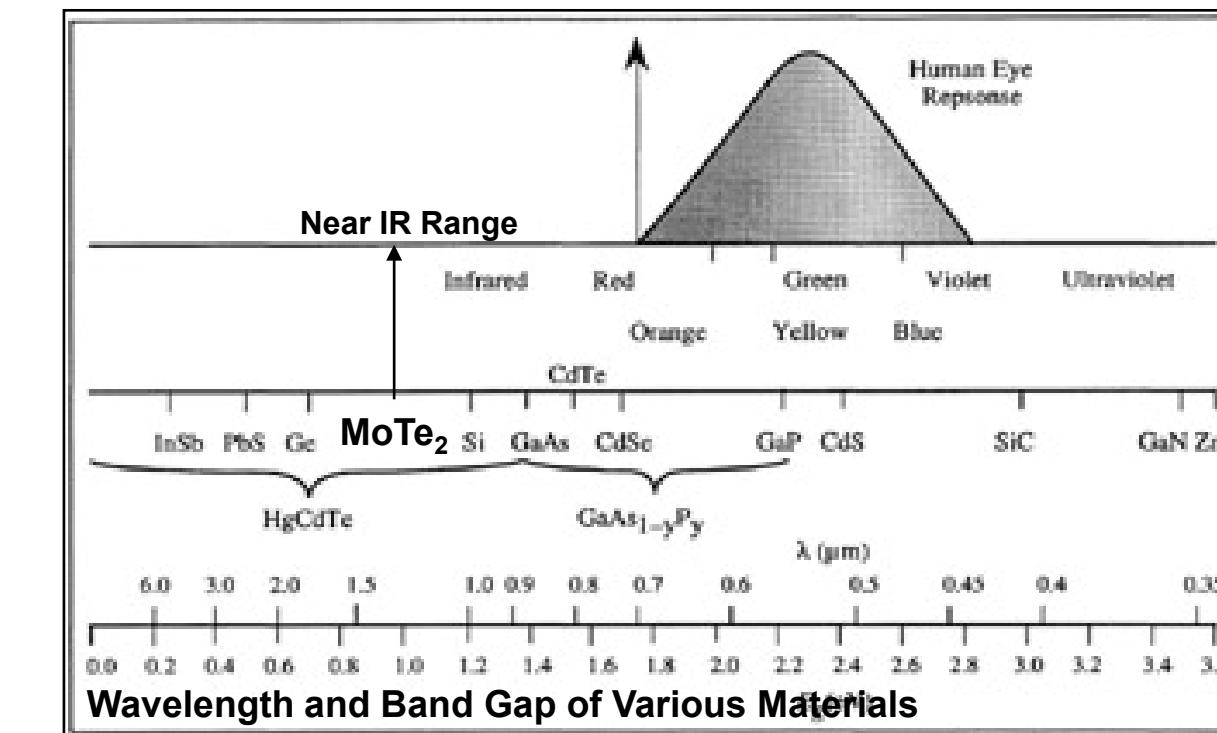
Custom Transfer Microscope



The transfer microscope takes two different layers of material and contacts them together via a multi-step polymer adhesion process. The Gabor group currently characterizes by atomic force microscopy, Raman spectroscopy, and photoluminescence spectroscopy. These characterization techniques will ultimately inform experiments that probe the novel optoelectronics properties of MoTe₂.



TMD Spotlight: MoTe₂

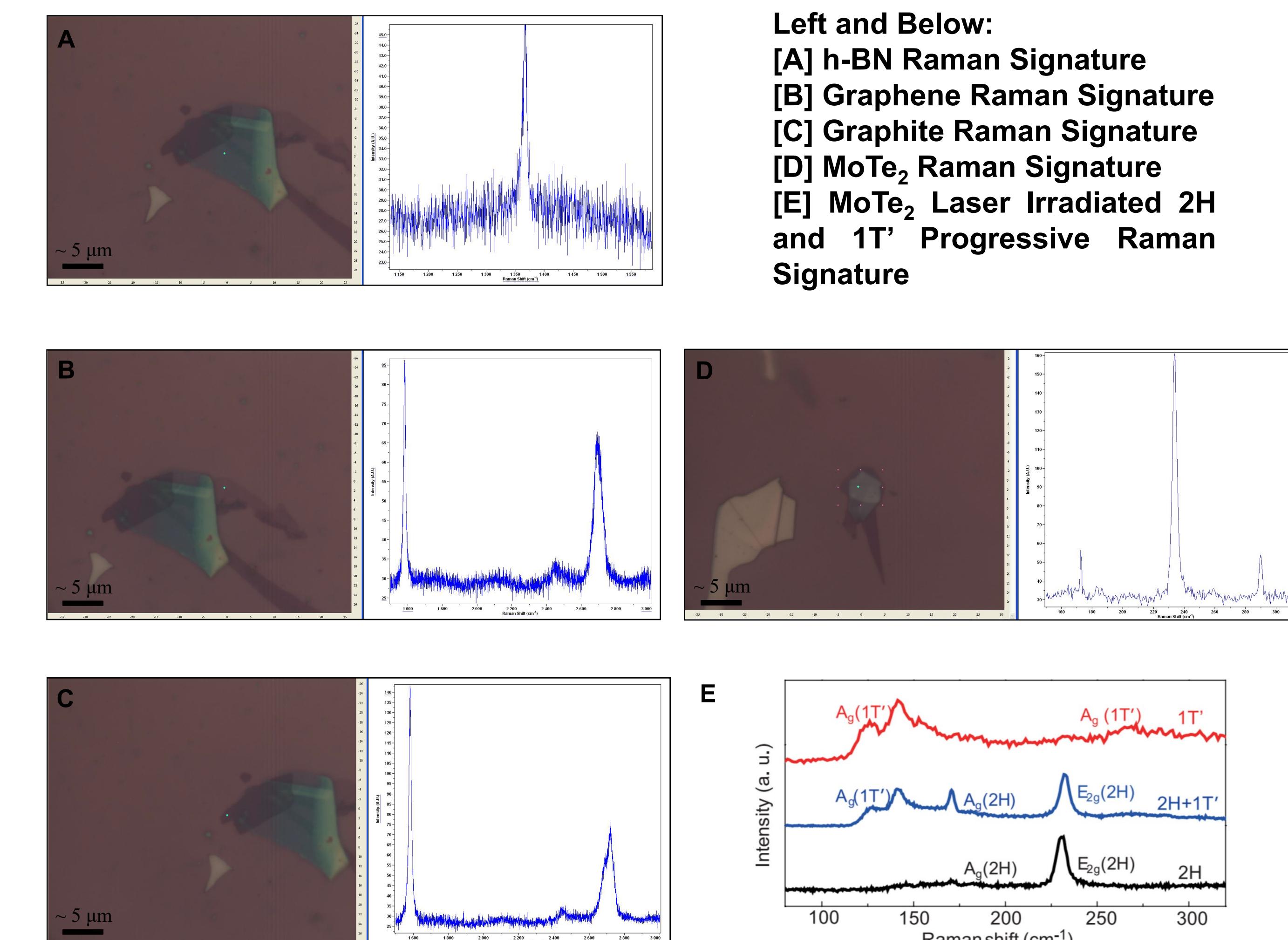
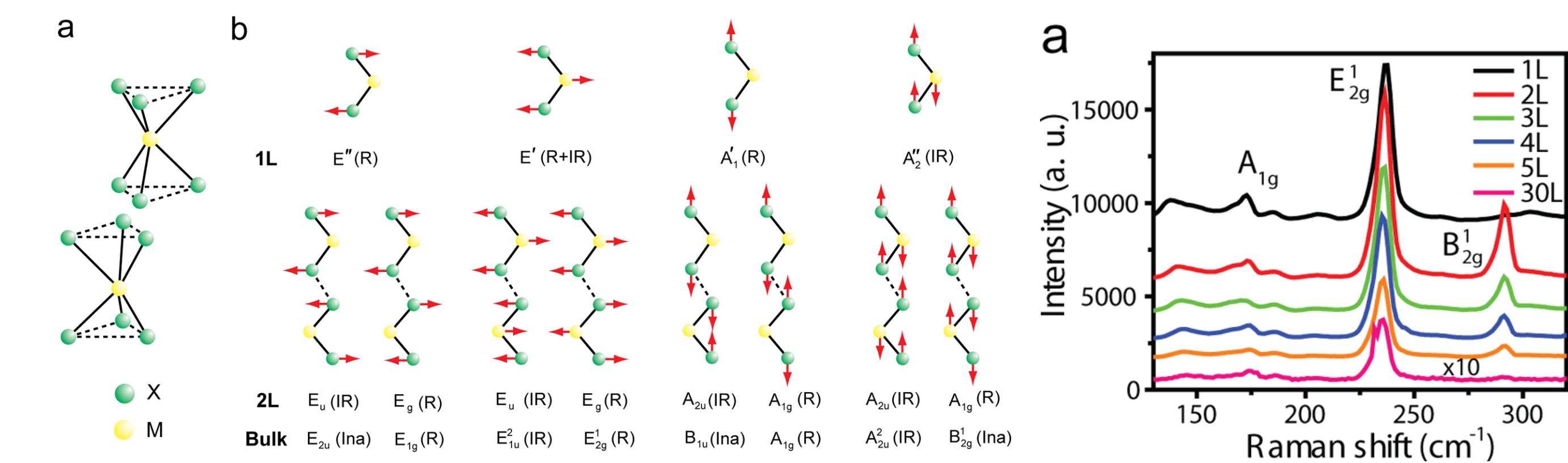


Ideal TMD flakes exhibit uniform surface area. As TMD layers near the monolayer limit, they begin to develop a tunable, direct band gap for use in optoelectronics.

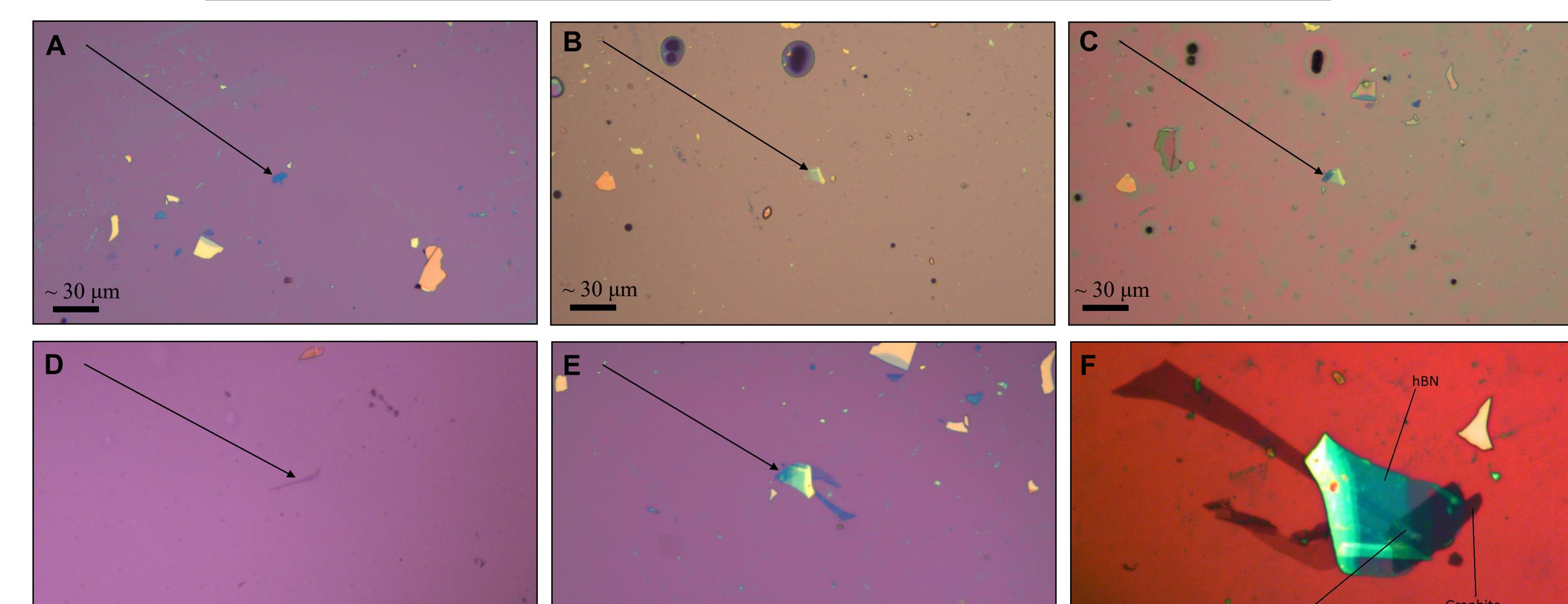
Discussion

Atomically thin semiconductors such as few-layered molybdenum ditelluride (MoTe₂) inspire new fields of research in condensed matter physics as well as materials science. Both fields share common interest in procuring atomically thin semiconductors with a tunable, finite band gap. Single layer MoTe₂ exhibits a band gap in the near infrared range, allowing for further research into electron-hole pairs in a 2D setting. Like other transition metal dichalcogenides (TMD), MoTe₂ exhibits a transition from an indirect band gap to a direct band gap as the material reaches the monolayer limit. In this work, we have successfully manufactured two and three layered MoTe₂ heterostructures by micro-mechanical exfoliation and semi-dry contact alignment transfer. With selected flakes, semi-dry transfer contact is done by the stacking of selected flake specimens using a custom transfer microscope to create heterojunctions. Hexagonal boron nitride is used in heterostructure synthesis to serve as a tunneling promoter to graphene. After heterostructure assembly, resultant structures are analyzed by measuring optical and optoelectronic response.

Raman Spectroscopy

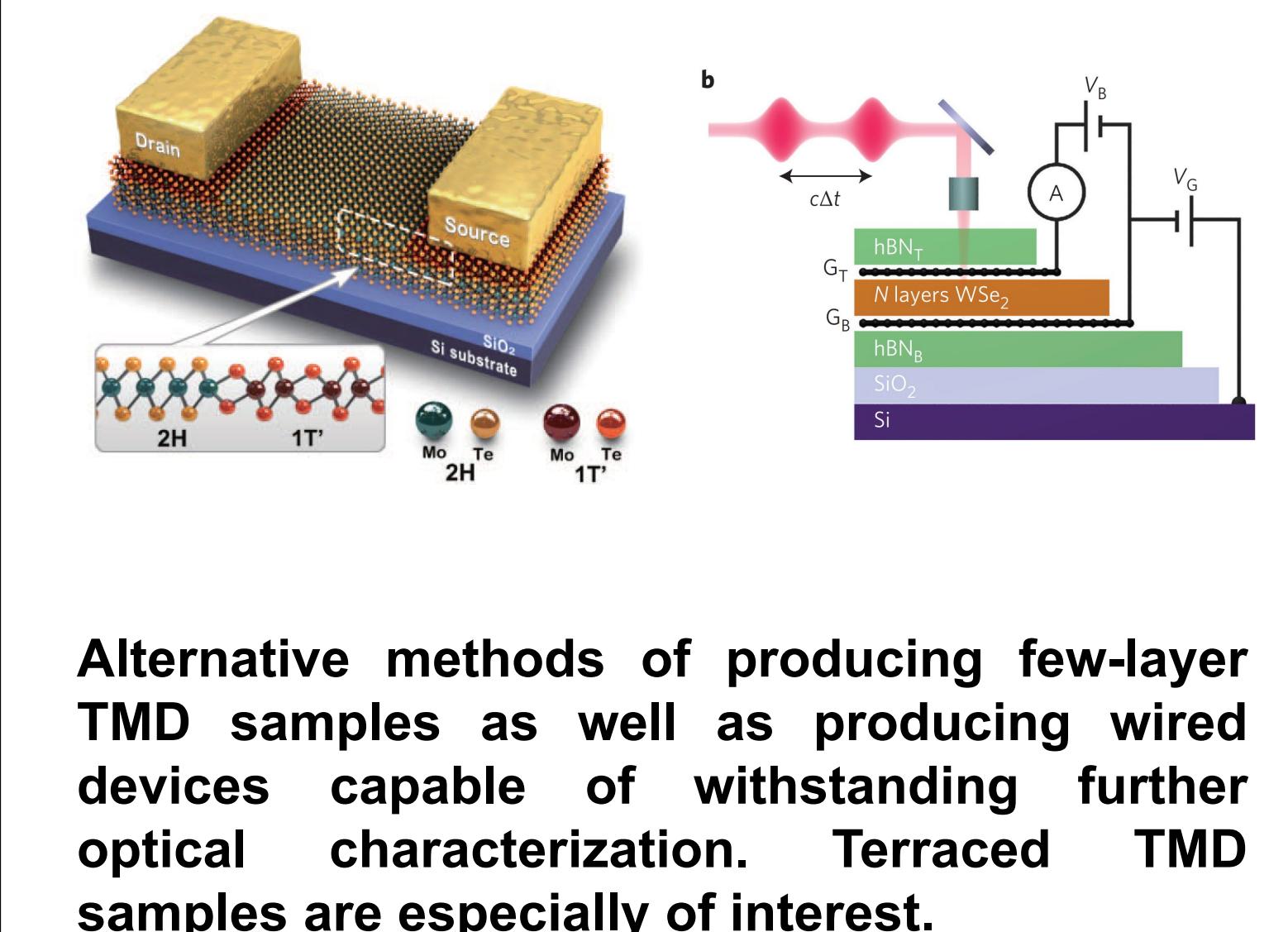
Suyeon, C. *Science*, 349(6248), p. 625-648. (2015)Yamamoto, M. *ACS Nano*, 8(4), p. 3895-903. (2014)

Heterostructure Fabrication

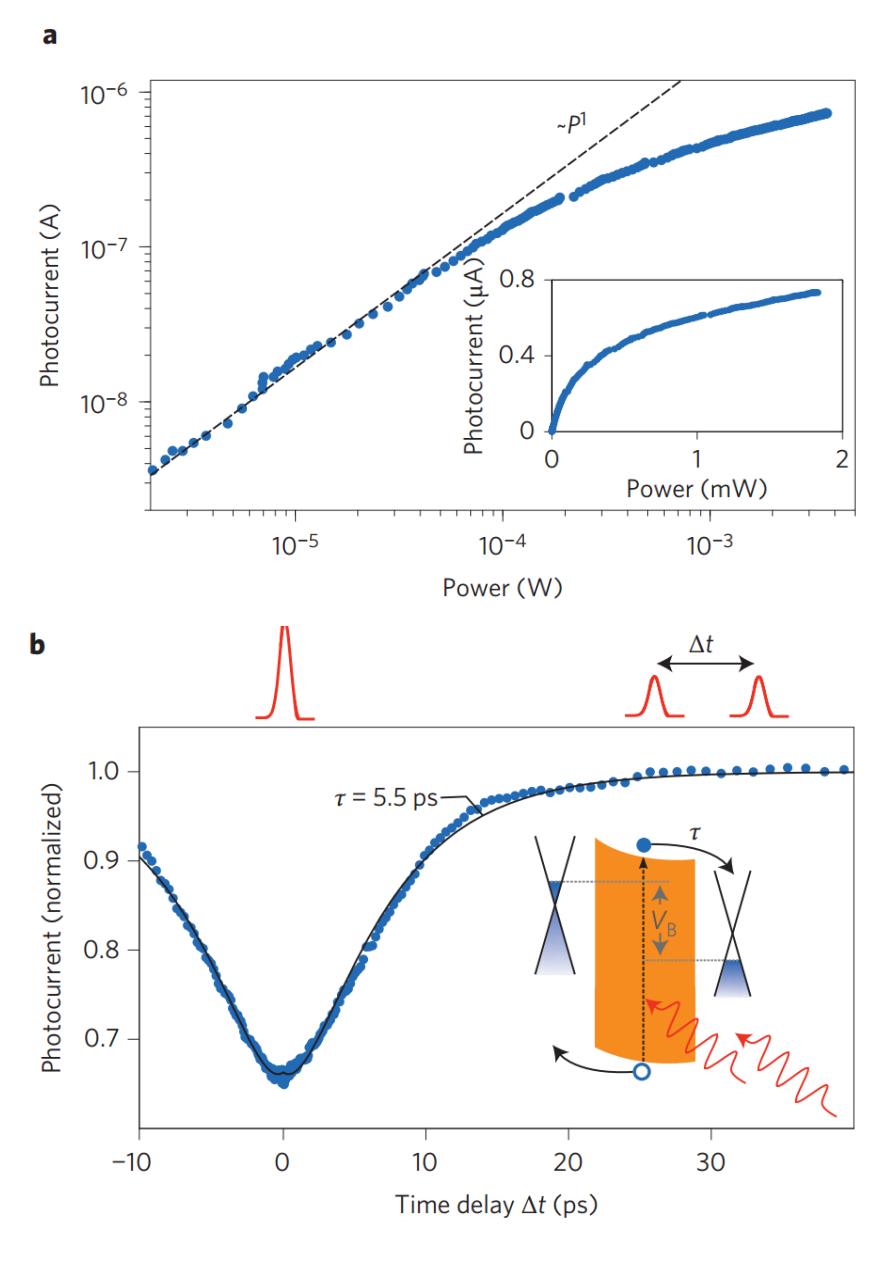


[A] Graphene 10x [B] h-BN on PPC 10x [C] h-BN on Graphene 10x
[D] Graphene 10x [E] Graphene/h-BN/Graphite 20x [F] Graphene/h-BN/Graphite 100x

Future Considerations



Alternative methods of producing few-layer TMD samples as well as producing wired devices capable of withstanding further optical characterization. Terraced TMD samples are especially of interest.

Massicotte, M. *Nature Nanotechnology*, 11(1), p. 42-46. (2015)Suyeon, C. *Science*, 349(6248), p. 625-648. (2015)